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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: :  
Jong-Dal HONG et al. : Art Unit: 1762  
Serial No.: 10/050,599 : Examiner: K. Jolley  
Filed: January 18, 2002 : Customer No.: 001609  
For: A PROCESS FOR FABRICATING :  
MONOLAYER/MULTILAYER :  
ULTRATHIN FILMS :  
:

**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In accordance with 37 C.F.R. § 1.97 and § 1.98, Applicants bring the disclosures attached and listed on completed Form PTO-1449 to the Examiner's attention and request that they be considered and made of record in this application.

An article by Cho et al entitled *Fabrication of Highly Ordered Multilayer Films Using a Spin Self-Assembly Method* is being submitted herewith. Its July 18, 2001 publication date is subsequent to the priority date of Applicants' Korean Application No. 2001-41773, filed July 11, 2001, but prior to the U.S. filing date. Three of the four authors are inventors named in the subject application. Submission of this article is not an admission that it constitutes prior art.

180.00 (P)

06/04/2004 00000119 10050599

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Submitted herewith is a check in the amount of \$180.00 to cover the fee specified in  
37 C.F.R. § 1.17(p).

Respectfully submitted,

  
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